

SEQUENCE LISTING

<110> Sawa, Yoshiki
Shintani, Takuji
Matsuda, Hikaru
AnGes MG, Inc.

<120> AGENTS FOR PROTECTION FROM NEOINTIMAL
FORMATION IN GRAFTS COMPRISING AN NFkappaB DECOY

<130> 082368-003400US

<150> PCT/JP02/13805

<151> 2002-12-27

<150> 2002-275884

<151> 2002-09-20

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